

Supplementary Material

Characterization of Thin MAPb(I_{1-x}Br_x)₃ Alloy Halide Perovskite Films Prepared by Sequential Physical Vapor Deposition

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Supplementary Figures

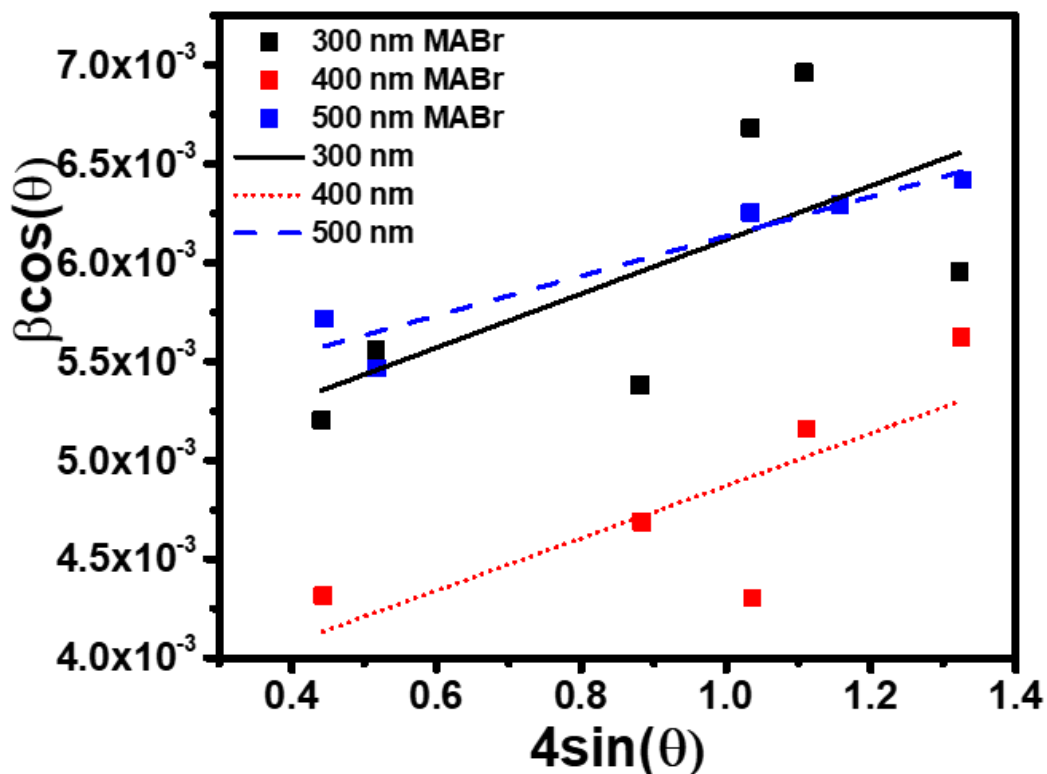


Figure S1. W-H plot of MAPb(I_{1-x}Br_x)₃ thin films for various MABr thicknesses.

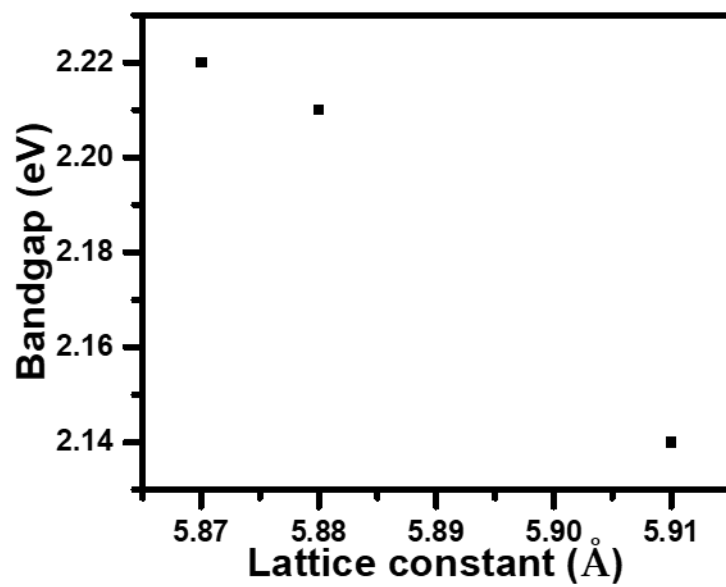


Figure S2. Bandgap of SPVD MAPb(I_{1-x}Br_x)₃ vs. lattice constant

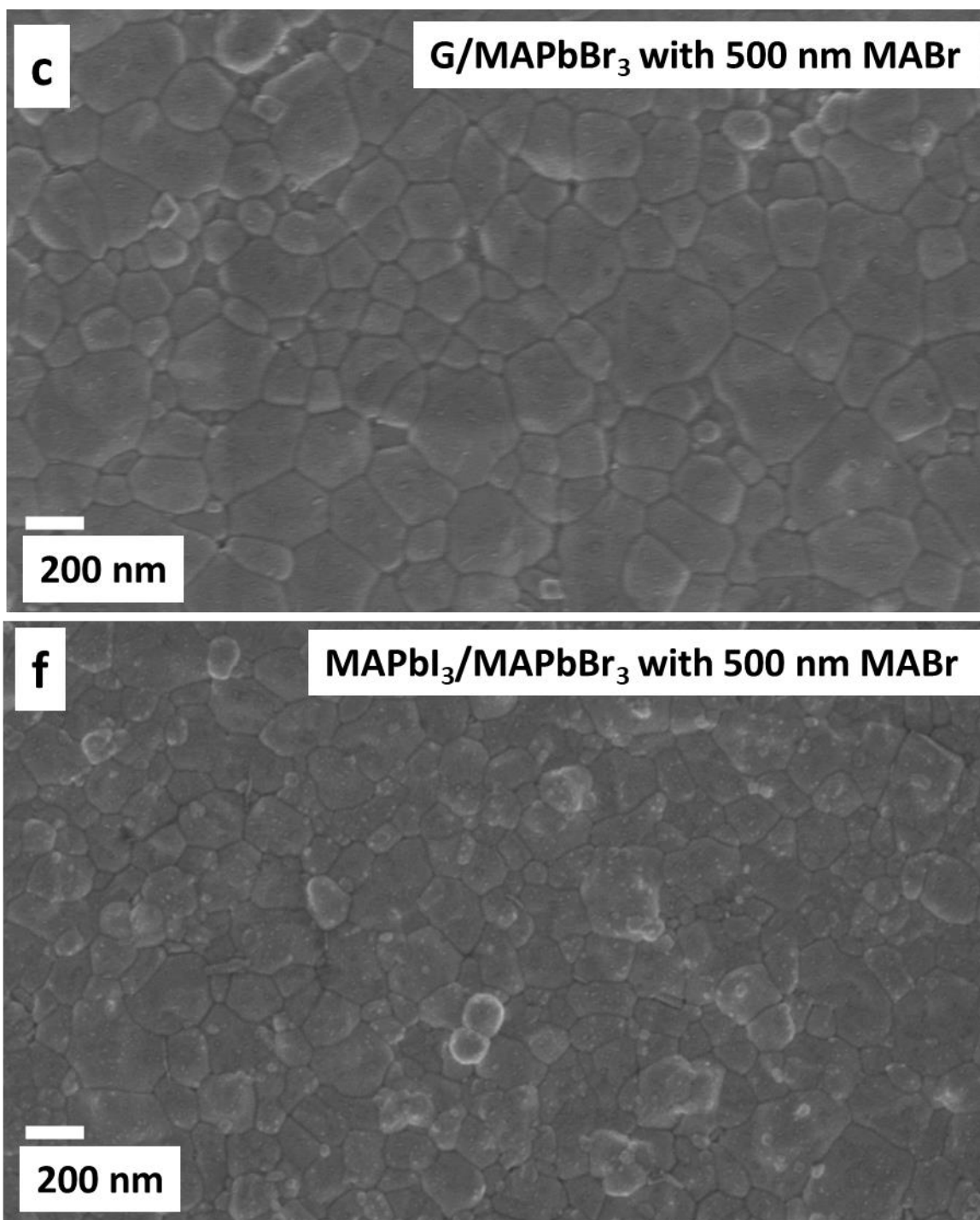


Figure S3. FE-SEM micrographs of (c) MAPbBr₃ and (f) MAPb(I_{0.05}Br_{0.95})₃ thin-films.

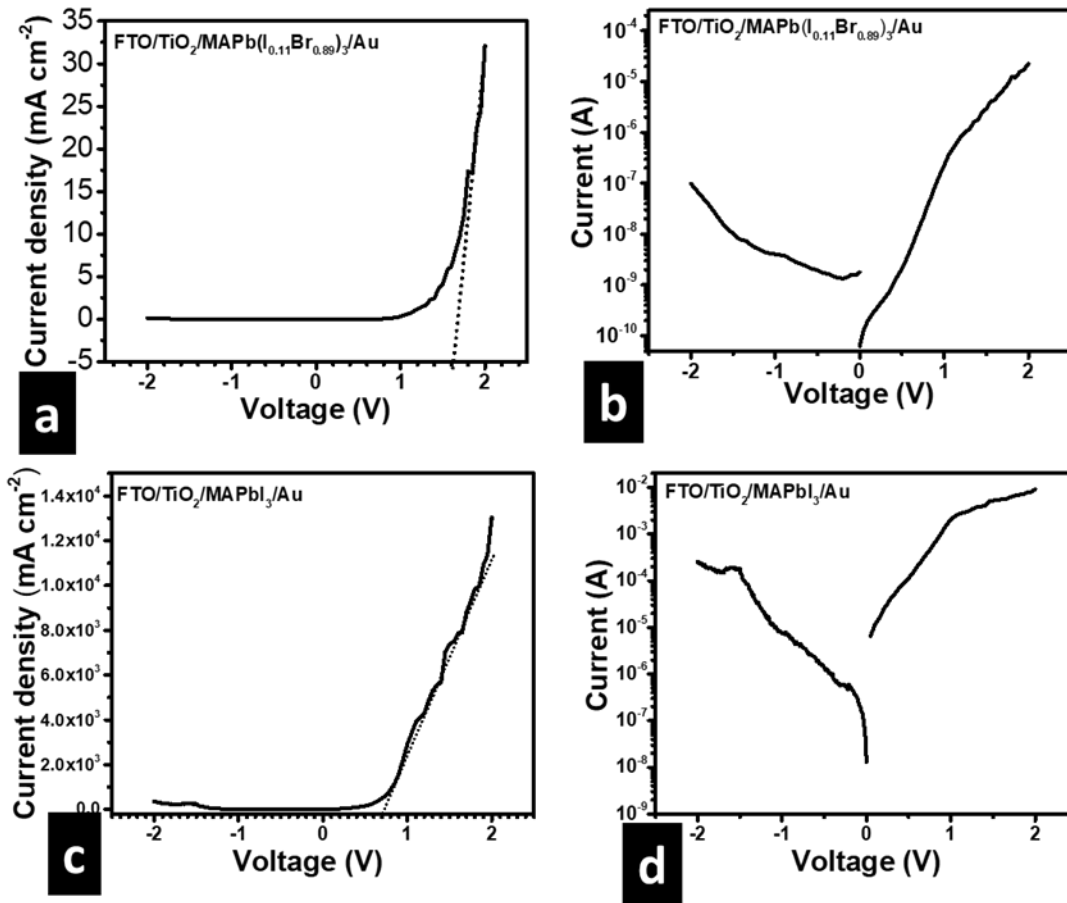


Figure S4. (a) J-V plots for FTO/c-TiO₂/m-TiO₂/MAPb(I_{0.11}Br_{0.89})₃/Au, (b) Semi-log plots for FTO/c-TiO₂/m-TiO₂/MAPb(I_{0.11}Br_{0.89})₃/Au (c) J-V plots for FTO/TiO₂/MAPbI₃/Au solar cells, (d) Semi-log I-V plots for FTO/TiO₂/MAPbI₃/Au solar cells.

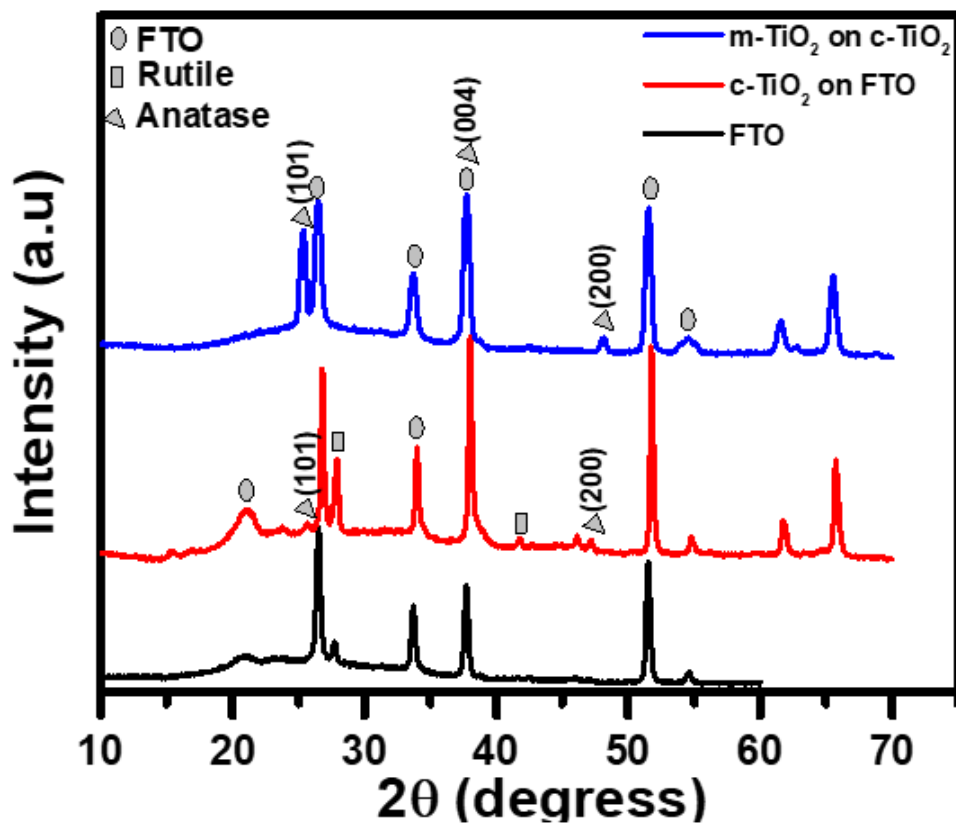


Figure S5: Diffractograms of c-TiO₂ and m-TiO₂

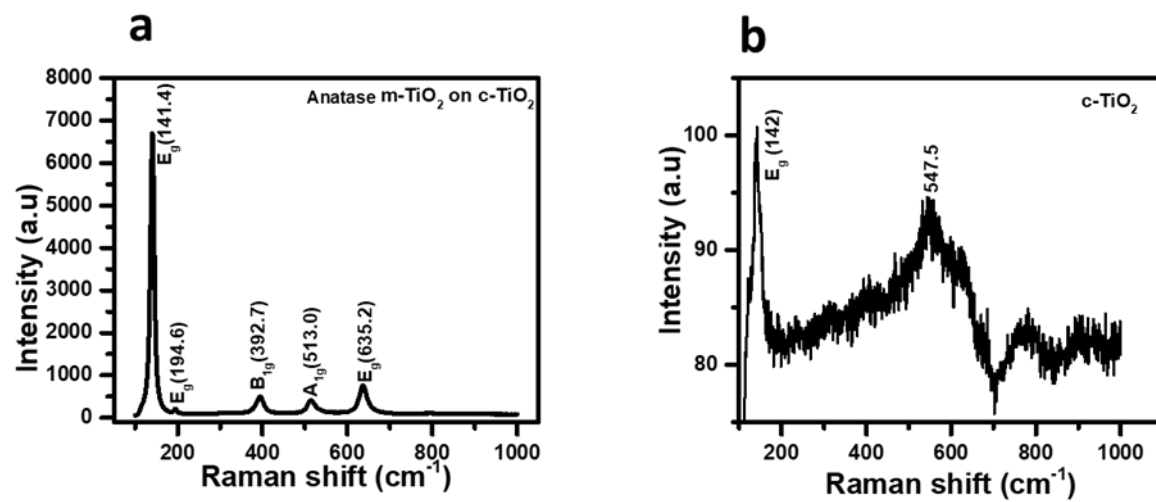


Figure S6: Raman of c-TiO₂ and m-TiO₂